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YS

**NONFERROUS METALS INDUSTRY STANDARD OF THE
PEOPLE'S REPUBLIC OF CHINA**

YS/T 893-2013

High-purity sputtering titanium target used in electronic film

电子薄膜用高纯钛溅射靶材

(English Translation)

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What this standard covers

This standard specifies the electronic film sputtering target with a high titanium requirements, test methods, inspection rules and signs, packaging, transportation, storage and quality certificates and contracts (orders) and so on. This standard applies

Document data

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